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Jul 13 '05 17:17

P. 03/05

Customer No.: 31561 Application No.: 10/707,825 Docket NO.: 10786-US-PA

<u>AMENDMENT</u>

Please amend the application as indicated hereafter.

In the Claims:

- 1 (original) A flip-chip gold bump structure formed on a wafer, comprising:
- at least one gold bump;
- a nickel layer on the gold bump; and
- a copper layer on the nickel layer.
- 2. (original) The flip-chip gold bump structure of claim 1, wherein the nickel layer has a thickness about from 0.1 μm to about 20 μm .
- 3. (original) The flip-chip gold bump structure of claim 1, wherein the copper layer has a thickness about from 0.1 μm to about 10 μm .
- 4. (original) The flip-chip gold bump structure of claim 1, wherein the gold bump has a height about from 3 μm to about 150 μm.
- 5. (original) A flip-chip package structure adapted to connect a chip and a chip substrate, comprising:
 - at least one gold bump on the chip;

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Jul 13 '05 17:17

P. 04/05

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a nickel layer on the gold bump; and

a solder containing copper on the nickel layer for connecting the chip and the chip substrate.

- 6. (original) The flip-chip package structure of claim 5, wherein the solder containing copper includes a solder alloy.
- 7. (original) The flip-chip package structure of claim 6, wherein copper in the solder alloy is from about 0.7 wt.% to about 3.0 wt.%.
- 8. (original) The flip-chip package structure of claim 5, wherein the nickel layer has a thickness about from 0.1 μm to about 20 μm.
- 9. (original) The flip-chip package structure of claim 5, wherein the gold bump has a height about from 3 μm to about 150 μm .

Claims 10-22 (canceled).